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UNITED STATES PATENT APPLICATION

OF

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FOR

Aqueous Cleaning Composition Containing Copper-Specific Corrosion Inhibitor For
Cleaning Inorganic Residues On Semiconductor Substrate

RELATED APPLICATIONS

This application claims the benefit of U.S. Patent Application NO. 09/818,073 filed March 3, 2001 which in turn claims priority of U.S. patent application No. 08/924,021 filed on August 29, 1997, which in turn claims the priority of U.S. Provisional Patent Application 60/044,824 filed April 25, 1997 and U.S. Provisional Patent Application 60/034,194 filed January 9, 1997. Additionally, this application claims priority to and repeats a substantial portion of prior U.S. Patent Application NO. 09/818,073 filed March 3, 2001 and U.S. Patent Application No. 08/924,021 filed on August 29, 1997. Since this application names AN inventor named in the prior application, the application constitutes a continuation in part of the prior application. This application incorporates by reference prior U.S. Patent Application NO. 09/818,073 filed Provisional March 3, 2001, U.S. Patent Application No. 08/924,021 filed on August 29, 1997, U.S. Patent Application 60/044,824 filed ON April 25, 1997 and U.S. Provisional Patent Application 60/034,194 filed ON January 9, 1997.

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